

Substitute for Form 1449 A & B/PTO

**INFORMATION DISCLOSURE
STATEMENT BY APPLICANT**

(use as many sheets as necessary)

Sheet

1

of

2

Complete if Known

Application Number	09/851,779
Confirmation Number	4385
Filing Date	May 08, 2001
First Named Inventor	Boaz KENAN
Art Unit	2623
Examiner Name	J. MANCUSO V. BALI
Attorney Docket Number	CA1130

U.S. PATENT DOCUMENTS

Examiner Initials*	Cite No. ¹	Document Number		Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document
		Number	Kind Code ² (if known)		
VB		US 6,016,357		01-18-2000	Neary et al.
VB		US 6,072,898		06-06-2000	Beaty et al.
VB		US 6,148,097		11-14-2000	Nakayama et al.
VB		US 6,075,883		06-13-2000	Stern et al.
VB		US 6,025,905		02-15-2000	Sussman
VB		US 6,052,478		04-18-2000	Wihl et al.
VB		US 6,018,392		01-25-2000	Tzu et al.
VB		US 6,081,659		06-27-2000	Garza et al.
VB		US 6,078,738		06-20-2000	Garza et al.
VB		US 5,745,168		04-28-1998	Ninomiya
VB		US 5,744,381		04-28-1998	Tabata et al.
VB		US 5,441,834		08-15-1995	Takekuma et al.
VB		US 5,272,116		12-21-1993	Hosono
VB		US 4,922,308		05-01-1990	Noguchi et al.
VB		US 4,148,065		04-03-1979	Nakagawa et al.
VB		US 5,572,598		11-05-1996	Wihl et al.
VB		US 6,091,845		07-18-2000	Pierrat et al.
VB		US 5,965,306	A	10-12-1999	Mansfield et al.
VB		US 6,335,129	B1	01-01-2002	Asano et al.
VB		US 5,576,829	A	11-19-1996	Shiraishi et al.
VB		US 2002/0171825	A1	11-21-2002	Krantz et al.

FOREIGN PATENT DOCUMENTS

Examiner Initials*	Cite No. ¹	Foreign Patent Document			Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Translation ⁶
		Country Code ³	Number ⁴	Kind Code ⁵ (if known)			

NON PATENT LITERATURE DOCUMENTS

Examiner Initials*	Cite No. ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city, and/or country where published.	Translation ⁶
VB		BUDD, RUSSELL A., et al., "A New Tool for Phase Shift Mask Evaluation, the Stepper Equivalent Aerial Image Measurement System - AIMS™," SPIE, Vol. 2087 Photomask Technology and Management (1993).	
VB		SCHENKER, RICHARD, "Comparison of Single and Dual Exposure Phase Shift Mask Approaches for Poly Gate Patterning," SPIE, Vol. 3546, September 1998.	
VB		LEVENSON, MARC D., et al., "Improving Resolution in Photolithography with a Phase Shifting Mask," IEEE Transactions on Electron Devices, Vol. ED-29, No. 12, December 1982.	
VB		BUDD, R.A., et al., "A New Mask Evaluation Tool, the Microlithography Simulation Microscope Aerial Image Measurement System," Optical/Laser Microlithography 7, San Jose, March 2-4, 1994, Proceedings of SPIE, Optical/Laser Microlithography, Bellingham, SPIE, US Vol. 2197, pages 530-540.	

Examiner Signature

Date Considered

12/13/05

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

¹ Applicant's unique citation designation number (optional). ² See Kind Codes of USPTO Patent Documents at www.uspto.gov, MPEP 901.04 or in the comment box of this document. ³ Enter Office that issued the document, by the two-letter code (WIPO Standard ST. 3). ⁴ For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. ⁵ Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST. 16 if possible. ⁶ Applicant is to indicate here if English language Translation is attached.

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

Complete if Known

Application Number	09/851,779
Confirmation Number	4385
Filing Date	May 08, 2001
First Named Inventor	Boaz KENAN
Art Unit	2623
Examiner Name	J. MANCUSE V. BALI
Attorney Docket Number	CA1130

Sheet	2	of	2
-------	---	----	---

[illegible][illegible][illegible]

Handwritten signature

Date Considered

12/13/05

¹ Applicant's unique citation designation number (optional). ² See Kind Codes of USPTO Patent Documents at www.uspto.gov, MPEP 901.04 or in the comment box of this document. ³ Enter Office that issued the document, by the two-letter code (WIPO Standard ST. 3). ⁴ For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. ⁵ Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST. 16 if possible. ⁶ Applicant is to indicate here if English language Translation is attached.